


Application Number 	Application/Control No. 10/514,411 <i>Johnson, C</i>	Applicant(s)/Patent and Reexamination YAMADA ET AL. <i>1752</i>
Document Code - DISQ		Internal Document - DO NOT MAIL

TERMINAL DISCLAIMER	<input checked="" type="checkbox"/> APPROVED	<input type="checkbox"/> DISAPPROVED
Date Filed : <i>8-24-06</i>	This patent is subject to a Terminal Disclaimer	

Approved/Disapproved by: <i>Dekker</i>

10/514,411	Photosensitive resin composition for original printing plate capable of being carved by laser	11-19-2009::13:05:42
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Bibliographic Data

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**(WO/2003/022594) PHOTSENSITIVE RESIN COMPOSITION FOR PRINTING PLATE
PRECURSOR CAPABLE OF LASER ENGRAVING**

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Latest bibliographic data on file with the International Bureau



Pub. No.: WO/2003/022594
Publication Date: 20.03.2003
Chapter 2 Demand Filed: 19.09.2002

International Application No.: PCT/JP2002/008811
International Filing Date: 30.08.2002

IPC: B41C 1/05 (2006.01), B41C 1/10 (2006.01), B41N 1/12 (2006.01), C08K 5/103 (2006.01), C08K 5/29 (2006.01), B41M 5/26 (2006.01)

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Priority Data: 2001-268892 05.09.2001 JP
2002-72002 15.03.2002 JP
2002-173022 13.06.2002 JP

Title: PHOTSENSITIVE RESIN COMPOSITION FOR PRINTING PLATE PRECURSOR CAPABLE OF LASER ENGRAVING

Abstract: A photosensitive resin composition for printing plate precursors capable of laser engraving which comprises: (a) 100 parts by weight of a resin which has a number-average molecular weight of 1,000 to 100,000, contains polymerizable unsaturated groups in a number of at least 0.7 per molecule on the average, and is a plastomer at 20°C; (b) 5 to 200 parts by weight of an organic compound having a number-average molecular weight lower than 1,000 and containing at least one polymerizable unsaturated group per molecule, and (c) 1 to 100 parts by weight of an inorganic porous material. Also provided is a printing plate precursor capable of being laser-engraved which is produced from the photosensitive resin composition.

Designated States: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, OM, PH, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW.
African Regional Intellectual Property Org. (ARIPO) (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW)
Eurasian Patent Organization (EAPO) (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM)
European Patent Office (EPO) (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, SK, TR)
African Intellectual Property Organization (OAPI) (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Publication Language: Japanese (JA)
Filing Language: Japanese (JA)